French Symposium on Emerging Technologies for micro-nanofabrication
Journées Nationales sur les Technologies Emergentes en micro-nanofabrication
Polytech Orléans
November 20-22, 2017

Synthesis of materials • Surface functionalization and processing • Etching – Lithography – Nano-patterning • Integration of technologies

The 3rd RENATECH thesis prize award at the JNTE 2017 symposium

Submission deadline: June 15th, 2017

Invited speakers and special guests (list available in April)
Joint Renatech technol. workshop

Visit http://jnte2017.sciencesconf.org or
Flash the code
SUBMISSION GUIDELINES
On-line submission dead-line: June 15th, 2017

For any inquiry, please contact:
jnte2017@sciencesconf.org

Language: The symposium is open to all actors of micro-nanotechnology in France, including students, post-doctoral fellows and visitors from foreign countries. For this reason, the language for all submitted contributions including the 2-page (max) abstract, and materials for oral and poster presentations is English. The language used by contributors during the symposium for their oral or poster presentations can be French or English.

General information: The paper submission is a two-step on-line process. Submissions should be performed using the paper submission interface on the JNTE 2017 website. All contributors should submit an abstract in pdf format (2 pages MAX including title, authors, authors affiliations, 50-word abstract, text, figures, and references). A paper template can be downloaded from the JNTE 2017 website.

Paper acceptance will be notified to the corresponding author around September 15th, 2017.

THE 3RD RENATECH TECHNOLOGY PRIZE WILL BE AWARDED AT THE JNTE 2017 SYMPOSIUM

The Thesis Prize awards
• an outstanding work in micro-nanofabrication,
• a thesis defended in 2015 or 2016,
• a thesis carried out in an academic or industrial French laboratory, possibly in collaboration with foreign partners.

The winner will be invited at a regular session of the JNTE symposium.


More information on the application and nomination procedure on the JNTE 2017 website.

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REGISTRATION - ACCOMMODATION
On-line registration will open in July 2017.

Registration fees:
The registration fees include conference registration, conf. proceedings booklet, free access to the exhibition area, breaks, lunches for the 2.5 days of the symposium and Tuesday social event dinner.

Accomodation:
A non-exhaustive list of hotels in Orléans is available on the JNTE 2017 website.